L	Hits	Search Text	DB	Time stamp
Number	111.03	Search lext		Time Stamp
1	5184	transistor and source and drain and	USPAT;	2004/03/30
		(exposing with substrate)	US-PGPUB	10:13
2	174	(transistor and source and drain and	USPAT;	2004/03/30
		(exposing with substrate)) and	US-PGPUB	10:12
3	122	(implanting same exposing same source)	,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,	2004/02/20
3	122	((transistor and source and drain and (exposing with substrate)) and	USPAT; US-PGPUB	2004/03/30
		(implanting same exposing same source))	US-FGFUB	10.00
		and @ad<20020118		
4	936	(transistor and source and drain and	USPAT;	2004/03/30
		(exposing with substrate)) and	US-PGPUB	10:00
	1	(implanting same source)		
5	2	((transistor and source and drain and	USPAT;	2004/03/30
		(exposing with substrate)) and	US-PGPUB	10:13
		(implanting same source)) and		
6	1653	@ad<20020118 and (print adj head) (transistor and source and drain and	USPAT;	2004/03/30
١	1055	(exposing with substrate)) and	US-PGPUB	10:29
		(implanting) and (exposing with		
		substrate)		
7	2	, , ,	USPAT;	2004/03/30
		(exposing with substrate)) and	US-PGPUB	10:13
		(implanting) and (exposing with		
		substrate)) and @ad<20020118 and (print adi head)		
8	1374	((transistor and source and drain and	USPAT;	2004/03/30
١	13/4	(exposing with substrate)) and	US-PGPUB	10:42
		(implanting) and (exposing with		
		substrate)) and @ad<20020118		·
9	4	(print adj head) and (implanting) and	USPAT;	2004/03/30
		(exposing with substrate)	US-PGPUB	10:30
10	11	(print adj head) and (implanting same	USPAT; US-PGPUB	2004/03/30
11	7452	source) (deposited with oxide) and transistor and	USPAT;	2004/03/30
**	/452	(implanting)	US-PGPUB	10:48
12	114	((deposited with oxide) and transistor	USPAT;	2004/03/30
	-1-	and (implanting)) and (print)	US-PGPUB	10:42
13	97	(((deposited with oxide) and transistor	USPAT;	2004/03/30
		and (implanting)) and (print)) and	US-PGPUB	10:54
1,,	105	@ad<20020118	EDO: TDO	2004/03/30
14	185	(deposited with oxide) and transistor and (implanting)	EPO; JPO; DERWENT;	2004/03/30
1		(Tubrancina)	IBM TDB	10.55
17	953	((insulating or insulator) same exposing	USPAT;	2004/03/30
		same substrate) and transistor and	US-PGPUB	10:54
		(implanting)		
19	10	1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	USPAT;	2004/03/30
1		exposing same substrate) and transistor	US-PGPUB	10:54
1		and (implanting)) and @ad<20020118) and		
18	754	print (((insulating or insulator) same exposing	USPAT;	2004/03/30
1 10	'34	same substrate) and transistor and	US-PGPUB	10:56
1		(implanting)) and @ad<20020118		
		1 /	L	